

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): M. FUNABASHI
 Serial No.: Not Yet Assigned
 (Divisional Application of SN 09/392,568
 Filed: September 9, 1999)
 Filed: July 12, 2001
 For: METHOD OF MANUFACTURING A SEMICONDUCTOR
 INTEGRATED CIRCUIT DEVICE

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents
 Washington, D.C. 20231

July 12, 2001

Sir:

Please amend the above-identified application, prior to
 examination thereof, as follows:

IN THE SPECIFICATION:

Please add the following new paragraph on page 1, between
 the title and the heading "BACKGROUND OF THE INVENTION":

-- This application is a Divisional application of
 prior application Serial No. 09/392,568, filed September 9,
 1999. --.

Please delete the paragraph bridging pages 2 and 3, and
 substitute therefor the following new paragraph:

-- Japanese Patent Application Laid-Open No. 6-41773
 discloses a technique in which an anti-adsorption agent (such
 as NTPO, EDTPO, EDDPO, or the like) is added to an aqueous
 solution containing an alkaline component such as ammonium
 hydroxide, hydroxide of alkaline metal (KOH or NaOH), choline,

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